SiPM: almost an Ideal Low Light Level Sensor for CTA SST

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What LLL sensor can we dream about ?

- Nearly 100 % QE and photon detection efficiency (PDE)
- Could be made in very large and in very small sizes
- Few ps fast (in air and in many materials the light speed is usually 20-30 cm/ns; in 5 ps it will make 1-1.5 mm)
- Signal amplification x10⁶
- Noiseless amplification: F-factor 1.001
- Few % amplitude resolution
- No fatigue, no degradation in lifetime
- Low power consumption
- Operation at ambient temperatures
- No danger to expose to light
- Insensitive to magnetic fields
- No vacuum, no HV, lightweight,...



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ILC: Potential Consumer of (5-200)x10⁶ SiPMs

→Scintillation Calorimetry- for instance a SciTile Imagine Hadron Calorimeter for ILC (CALICE Collaboration),sci tile size:a few cm

→Typical threshold is ~ 5-7 phe



SiPM tile fibre system

- SiPM developed by MEPhI/PUSAR
 - Gain ~10°, bias ~ 50 V, size 1 mm², 1156 pixels
 - Eff (green) ~ 15%, quenching R ~ 1 10 MΩ
- SiPM tile fibre system integration: ITEP
 - 3x3x0.5 cm³ tiles from UNIPLAST, Russia
 - WLS fibre Kuraray Y11(300) 1mm
 - Matted edges, 2% light xtalk per edge
 - Faces covered with EM mirror foil







CAL CO

MSFDs for calorimetry



A big 8000 channel HCAL prototype with tail catcher is constructed by CALICE (DESY,ITEP,LAL,MEPHI,NIU,Prague,UK) for analogue and semidigital modes







B.Dolgoshein,SiPM review



One plane with SiPMs and WLS fibers installed into 3x3, 6x6 and 12x12 cm² 0.5 cm thick tiles

CERN test beam,2006

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FACT = First G-APD Cherenkov Telescope for TeV Gamma Astronomy

TU Dortmund, EPF Lausanne, U Würzburg, ETH Zürich

Goal:

- Crab-observations in the coming period
- Test the technology (CTA, AGIS, MAGIC, ...)
- Will be operated for the DWARFprojects physics program !

Ready availability

- HEGRA-3 Telescope-Mount (La Palma):
- 8.5 m² mirror of good reflectivity
- Microcontroller-based Drive system
- Experience with 36 Pixel-Test camera M0







Why the light emission from Si avalanches is so important

- First observation of the light emission from reversed-biased Si p-n junction in 1955 (Newman)
- Revived interest about the effect in recent years because of:
- Cross-talk in SiPMs (GAPD, MPPC, micro-channel APD,...) spoils the amplitude resolution
- The light emission is proportional to the number of e- in the avalanche. This puts a limit to the maximum gain under which one can operate the SiPMs
- If no measures are taken against the cross-talk, then the Ffactor is worse than in classical PMTs
- As a consequence one encounters major problems in selftrigger schemes when measuring very low light level signals



When an avalanche is triggered in one SPAD we have:

- Secondary photons emission due to the avalanche current
- Photons propagation throughout the chip
- Secondary photon detection by a nearby detector



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Current status of SiPM and the prospects

- Currently there is a lot of enthusiasm about the new devices but the deep understanding is not simple, it comes only slowly
- One of the main problems of SiPMs is the low PDE, that is not easy to measure. It shall be disentangled from the cross-talk and afterpulsing.
- The afterpulsing in PMTs is a ~1% effect on single ph.e. level, while for example, for currently existing MPPC's from Hamamatsu it is a 20-30 % effect. This shall strongly manifest itself in self-trigger mode
- Usually the real value of PDE is much lower than the claimed (advertised) one. The reason is the low applied overvoltage.
- For ~100 % Geiger efficiency and a high PDE one needs to apply an overvoltage that is 15-20 % higher than the breakdown one. The commercially available devices cannot do this yet (because of their design they do not quench above an applied overvoltage of 2.5 %).
- Already during this year some type of SiPMs with good UV response and a low cross-talk level could become available.
- Hamamatsu, Philips, Perkin-Elmer and some other companies are working on it.

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→ Long tail in SiPM pulse hight distribution vs threshold



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Optical Crosstalk OC

P. Buzhan, B. Dolgoshein, et al., 2009

OC has two components

FIRST:phe's are induced in high electric field depletion region of neibouring pixels

>this mechanism is very fast: ~1ns(prompt OC)

SECOND : The same in undepleted region and then the diffusion(or drift) to high electric field Geiger region of neibouring pixels

 \rightarrow this process is delayed: later than 1ns



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A filled in trench



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First step: SiPM 1.4x1.4 mm2 with OC suppression topology



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Timing by SiPM: possible application for Cherenkov Imaging Counters



SiPM:

• position sensitive (~1 mm²)

 a single photon detection capability with background hits density : 2.10⁻³ 1/ns·mm² (room temperature) 3.10⁻⁴ 1/ns·mm² (-50°C) insensitive to magnetic field
good time resolution (~50 ns rms)

FWHM: Laser (40 ps) + electronics (60 ps) => SiPM (100 ps)

Second step: 5x5mm2 SiPM with OC and AP suppression

SiPM parameters:

🗲 size

5x5mm2

- → double junction structure with optical barriers 6mkm
- \rightarrow number of pixels
- → pixel size
- → gain
- → geometrical eff.(filling factor)
- → pixel capacitance
- → output SiPM capacitance
- → antireflection entrance window
- → single pixel recovery time

1600 100mkm 2×10*7 64% ~1pF ~160pF

~ .5mks





Figure 3: $25(5 \times 5)mm^2$ SiPM. It consists of the array of $1600(40 \times 40)$ micropixels with $100 \times 100 \mu m^2$ size.

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Timing by 5x5mm2 SiPM: signal shape

- Because high SiPM output capacitance (~160pF)
 - a special FE electronics has been developed: low imput impedance(a few Ohm) current amplifier+shaper



→ The lifetimes of trapped electron are mostly rather small: less than ~100 ns



Therefore a single pixel recovery time Rquench x Cpixel sould not be not very small and recommended at level of .5-1 mks →Even for high Gain x PDE the Afterpusing has to be small enough: AP(Gain=10*7)=~1% for recovery time of >500ns

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The cross-talk effect (optical coupling: OC) has a major impact in self-trigger schemes, it can prohibit obtaining a low threshold setting



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Prompt OC suppression using Si damaged by ion implantation



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Dark count rate: SiPM 1x1mm^2, OC=4%,AP=1% room temperature

SiPM 1x1 mm² P on N , (pixel size size 100x100 µm) with OC and AP suppression



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Digital SiPM

→single pixel dark
 count rate is lower by
 factor of 1.5-2
 (~physical limit)
 →digital output is
 more convenient for
 system integration

→PDE loss (filling factor is less due to electronics on chip)
 →problems with
 Optical Crosstalk and Afterpulsing have to be solved

Fabrication cost?

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PHILIPS

Digital Photon Counting – The Concept

Intrinsically, the SiPM is a digital device: a single cell breaks down or not



Philips Digital Photon Counting, October 27th, 2009

R. Mirzoyan: SiPMs for CTA SST, SST meeting, Liverpool

www.philips.com/digitalphotoncounting

PDE ,SiPM p on n,3x3 mm², OV/V=12% +OC suppression

Test-product of PEI, to become soon commercial product

SiPM 3x3 mm² P on N (pixel size 100x100 μ m, geom. eff. = 0,6) T = -50 $^{\circ}$ C



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Conclusions

- In a time scale 1-2 years from now one can buy SiPMs with outstanding characteristics, probably from several manufacturers.
- Their sizes could span 1-10 mm.
- SiPM cost will be reduced due to the availability of full CMOS designs. Several USD per mm² is not unrealistic.
- They could offer PDE of 60-65 %, x-talk < 1% and low temperature and voltage dependences.
- These devices are going to substitute classical PMTs and APD in many applications, including those in physics instrumentation in, for example, nuclear medicine (timeof-flight PET,...).
- Realistic candidates for SST telescopes, especially for 2optical element designs

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